1. Exposure Time (**Negative Photoresist**)= **15 sec / side**

2.Exposure Time (**Solder Mask**)= **1min 30 sec / side**

2. When cleaning the unexposed photoresist, **don't wait for all unexposed one to dissolve in the Na2Co3 solution. If I wait till that point, it's already too late and it starts destroying the exposed one also by then.**Instead, **when you see the unexposed one just start dissolving, rinse it under water to get rid of it completely**